CLAIMS

- A device, which comprises a surface layer that has incorporated therein at least one radioactive nuclide.
- A device which comprises a substrate and a selfassembled layer that has incorporated therein at least one radioactive nuclide.
- 3. A device according to claim 2, wherein the substrate is selected from the group consisting of stainless steel, Nitinol, silicon, quartz, cobalt chrome and polymers.
- A device according to claim 1, wherein the selfassembled layer is an anchored SAM.
- 5. A device according to claim 2, wherein the anchored SAM is selected from the group consisting of monolayers or films anchored by siloxane, thiol, amine or phosphonate.
- 6. A device according to claim 1, comprising a substrate of a metal selected from the group consisting of stainless steel and Nitinol and a self-assembled layer anchored by phosphonate.
- 7. A device according to claim 1, wherein the surface layer is formed of a radioactive material.
- 8 A device according to claim 1, wherein the surface layer is formed of a radioactive material that has been activated to induce radioactivity therein after its final formation.
- 9. A device according to claim 1, which comprises a chemically functionalized SAM incorporating radionuclides attached at the surface of the device.
- 10 A device comprising a substrate covered on all its surfaces by a self-assembled layer, which layer includes radioactive nuclides, and having no other protective layer or coating over said self-assembled layer.
- 11. A temporary or permanent therapeutic implant, comprising a substrate and a radioactive self-assembled surface layer.

- 12. An implant according to claim 11, wherein the self-assembled surface layer is an anchored SAM.
- $$13.\ A$$ device according to claim 11, which is a stent for use in angioplasty.
- 14. A device according to claim 11, wherein the surface layer has a thickness of less than 10 nm.
- 15. A device according to claim 11, wherein the substrate is made of Nitinol.
- 16. A device which comprises a substrate and a self-assembled layer that has incorporated therein at least one radioactive nuclide, wherein the nuclide is selected from the group consisting of I-131, F-18, C-11, Br-83, Br-82 and Cu-64.
- 17. Process for making a device according to claim 1, which comprises providing a substrate, forming on the substrate a self-assembled surface layer, and providing said self-assembled layer with a radioactive material.
- 18. Process according to claim 17, wherein the surface layer is made of radioactive material.
- 19. Process according to claim 17, wherein the surface layer is made of non-radioactive material and is then labeled with a radionuclide.
- 20. Process according to claim 17, wherein the self-assembled surface layer is a chemically functionalized SAM incorporating radionuclides.
- 21. Process according to claim 17, wherein the self-assembled surface layer is labeled with iodine.
- 22. Process according to claim 21, wherein the surface layer is labeled with iodine by adding radioiodide in the presence of an oxidant.
- 23. Process according to claim 14, wherein the [substrate] surface layer is labeled with fluorine-18 or carbon-11.
- \$24.\$ Process according to claim 15, wherein the substrate is made of a material selected from the group consisting of silicon, quartz and Nitinol.

- 25. Process according to claim 20, wherein the SAM is a siloxane-anchored SAMs based on functionalized alkyltrichlorosilanes.
- 26. Process according to claim 29, wherein the substrate is made of a material selected from the group consisting of stainless steel and cobalt chrome which have native oxide layers.
- 27. Process according to claim 26, wherein the native oxides are enhanced by applying an overlayer of silicon oxide.
- 28. Process according to claim 17, wherein the self-assembled surface layer is formed by a solution-based process.
- 29 Process according to claim 17, wherein the selfassembled surface is provided with a radioactive material by in situ covalent attachment of radionuclides.
- 30. A kit for the preparation of a device according to claim 1, which comprises a solid device bearing a functionalizable thin film and the reagents for derivatizing said film with a radionuclide or a radionuclide-containing material.
- 31. A kit for the preparation of a device according to claim 1, which comprises a solid device that is not coated with a functionalizable thin film but rather provides the means for applying such a film to it, and, optionally, means for derivatizing said film with a radionuclide or a radionuclide-containing material.
- 32. A process for the preparation of a device according to claim 1, which comprises providing a kit which comprises a solid device bearing a functionalizable thin film and the reagents for derivatizing said film with a radionuclide or a radionuclide-containing material, and carrying out the derivatizing when the device is to be used.
- 33. A process for the preparation of a device according to claim 1, which comprises providing a kit which comprises a solid device that is not coated with a functionalizable thin film but rather provides the means for

applying such a film to it, and, optionally, means for derivatizing said film with a radionuclide or a radionuclide-containing material, and carrying out the application of said film and the derivatization thereof when the device is to be used.

- 34. Method of applying radioactive radiation to an organ or vascular structure of the human body, which comprises providing a device according to claim 1, and inserting said device into said organ or vascular structure.
- 35. Method of applying radioactive radiation to an organ or vascular structure of the human body, which comprises providing a solid device at or near the time and location at which radioactive radiation is to be applied to said organ or vascular structure, applying to said device a surface layer that has incorporated therein at least one radioactive nucleide, whereby to generate a device according to claim 1, and then inserting said radioactive device into said organ or vascular structure.